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Synthesis of hierarchical NiS microflowers for high performance asymmetric supercapacitor

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23 1. Introduction

24 Supercapacitors (SCs), also electrochemical capacitors, have received intense
25 attention because of their higher power density than secondary batteries and higher
26 energy density than conventional dielectric capacitors. These superior advantages
27 enable them promising in various areas, such as portable electronic devices, hybrid
28 electric vehicles, and back-up power supplies [1-4]. Based on the charge storage
29 mechanism, SCs can be typically classified into electrical double-layer capacitor
30 (EDLCs) and pseudocapacitors. EDLCs build up an electrical charge at the
31 electrode-electrolyte interface, whereas pseudocapacitors based on the fast, reversible
32 redox reaction take place on or near the surface of electroactive material [5-9].
33 EDLCs based on carbonaceous materials, such as activated carbon, carbon nanotubes
34 and graphene, etc. The carbon materials have high electric conductivity and long life
35 cycle, but they usually suffer from the small double-layer capacitance. Alternatively,
36 pseudocapacitors use transition metal oxides/hydroxides as well as conducting
37 polymers as the electroactive materials such as RuO_2 , MnO_2 , Ni(OH)_2 and PANI, etc.
38 Compared with EDLCs, pseudocapacitors could provide higher specific capacitance
39 (C_m), attributing to the fast and reversible redox reaction on the surface of
40 electroactive materials [10-12]. Among the numerous transition metal oxides, RuO_2
41 exhibits tremendous application potentiality as a promising electroactive material due
42 to its high theoretical specific capacitance, good electric conductivity and long cycle
43 lifetime. However, its resource scarcity, high cost and toxic nature limits its widely
44 commercial application [13]. Hence, much effort has been focused on alternative

45 electrode materials with low price, environmentally friendly and good capacitive
46 performance such as MnO_2 [14], NiO [15], Co_3O_4 [16], $\text{MnCo}_2\text{O}_{4.5}$ [17] and V_2O_5 [18]
47 and so forth. Nonetheless the conductivity of transition metal oxides is too low to
48 favor rapid electron transport at high rate capability, which limits its extensive
49 application in practice [19].

50 Recently, transition metal sulfides such as FeS_2 , CuS , MoS_2 , NiS_2 and CoS_2
51 possess promising application future in areas of hydrogen evolution reaction catalysts,
52 sensors, solar cells, lithium ion batteries and SCs due to their unique optical and
53 electrical properties [20-28]. Compared with corresponding oxides, transition metal
54 sulfides have higher conductivity, mechanical and thermal stability and richer redox
55 reactions. Therefore, they have better capacitance performance and potential to be
56 applied to electroactive materials for SCs [29-34]. As one of the important class of
57 transition metal chalcogenides, nickel sulfides exist various phases, such as NiS , NiS_2 ,
58 Ni_3S_2 , Ni_7S_6 and Ni_9S_8 . Among them, NiS receives more attention owing to its
59 excellent capacitance performance, high redox activity, safety and low price, which
60 are expected to satisfy the increasing needs of energy storage systems [35-41].

61 As is known, the morphology and structure of electroactive materials have a key
62 influence on electrochemical behaviors. Thus many researchers desire to develop
63 distinctive morphological NiS in order to design electrode materials with large surface
64 and rough surface to improve the wettability of active materials and short diffusion
65 paths for electrolyte and charge transports [42,43]. A comparison of C_m of NiS
66 microflowers with other forms of NiS , as can be indexed in Table 1. Nevertheless, as

67 for the synthesis process of samples, the usage of expensive organic solvent and
68 template is unfavorable to its widely application in practice.

69 Herein, we report a facile sacrificial template method to synthesis hierarchical
70 NiS microflowers—sulfidizing Ni(OH)₂ precursor with thiourea in absolute ethanol.
71 The hierarchical structure with high specific surface area can improve the density of
72 active sites, and enhanced the electron transferring and ion diffusing rate, respectively
73 [47]. When applied as the electroactive materials for SCs, the hierarchical NiS
74 microflowers electrodes show a high C_m of 1122.7 F·g⁻¹ at 1 A·g⁻¹, good cycling
75 stability and rate capability. Furthermore, in order to evaluate the practical application
76 of NiS, an asymmetric supercapacitor, NiS as the positive electrode and activated
77 carbon (AC) as the negative electrode, was assembled (named as NiS//AC). The
78 NiS//AC has extended the operating voltage to 1.8 V in 3 M KOH electrolyte, and
79 achieved energy density of 31 Wh·kg⁻¹ with a power density of 0.9 kW·kg⁻¹.
80 Meanwhile, the NiS//AC shows a superior cycling and coulombic efficiency. This
81 study reveals the hierarchical NiS microflowers are a promising candidate for high
82 performance SCs.

83 2. Experimental

84 2.1. Synthesis of Ni(OH)₂ precursors

85 The synthesis of hierarchical NiS microflowers is depicted in Fig. 1. Typically,
86 0.872 g of Ni(NO₃)₂·6H₂O and 0.364 g of urea were dissolved in 40 mL of deionized
87 water to obtain a pale green solution under vigorous stirring. Then 0.012g trisodium
88 citrate was added to the resulting dispersion. After stirring for 30 min, the resulting

89 solution was transferred in to a 50 mL Teflon-lined stainless autoclave and kept
90 150 °C for 24 h. Finally, the autoclave was cooled to room temperature naturally. The
91 green precipitates were collected and washed with deionized water and absolute
92 ethanol several times by centrifugation, and then dried at 60 °C for 8 h.

93 *2.2. Synthesis of hierarchical NiS microflowers*

94 For the formation of NiS microflowers, 0.106 g of the as-obtained precursor was
95 dispersed in to 40 mL of absolute ethanol, followed by addition of 0.228 g of thiourea.
96 After thorough stirring for 5 min, the mixed solution was transferred in to a 50 mL
97 Teflon-lined stainless autoclave and heated at 120 °C for 24 h, and then cooled down
98 to room temperature naturally. The black precipitates were collected by centrifugation,
99 washed with deionized water and absolute ethanol several times, and dried under
100 60 °C for 8 h. The productivity of the NiS microflowers is 93.64%.

101 *2.3. Materials characterization*

102 The crystallographic information of the as-prepared samples was characterized
103 by X-ray diffraction (XRD, Bruker, D8 Advance, Germany) with Cu K α radiation
104 ($\lambda=1.5406$ Å). Chemical valence states and elemental composition of the samples
105 were analyzed by X-ray photoelectron spectroscopy (XPS, Thermo Science,
106 ESCALAB 250Xi, USA). Morphology and structure were analyzed by scanning
107 electron microscopy (FESEM, Hitachi, S-4800 II , Japan) equipped with an
108 energy-dispersive X-ray spectroscopy detector (EDS), transmission electron
109 microscopy (TEM, Philips, TECNAI12, Holland) and high resolution transmission
110 electron microscope (HRTEM, FEI, TECNAI G2F30 S-TWIN, USA). The surface

111 areas and the pore-size distribution were measured on N₂ adsorption analyzer
 112 (Micromeritics, TriStar 3000, USA).

113 2.4. Electrochemical measurements

114 Electrochemical tests of as-obtained samples were performed in a three-electrode
 115 mode in 3 M KOH solution, the Ag/AgCl and platinum plate as the reference and
 116 counter electrodes, respectively. The working electrode was prepared by mixing the
 117 active material, conductive graphite and polytetrafluoroethylene (PTFE) in a mass
 118 ratio of 80:15:5. A proper amount of absolute ethanol was then added to the mixture to
 119 promote homogeneity. The slurry mixture was smeared into the Ni foam substrate
 120 (1×1 cm²), dried at 60 °C for 12 h to remove the absolute ethanol fully, and then
 121 pressed into a thin foil at a pressure of 10 MPa. The active material mass of a single
 122 electrode is about 2~2.5 mg.

123 The NiS//AC was fabricated based on NiS positive electrode and active carbon
 124 (AC) negative electrode. Preparation method of positive and negative electrode was
 125 same. The NiS//AC was separated with a glass fiber filter paper, and performed in a
 126 two-electrode system in 3 M KOH electrolyte. As for NiS//AC, the charge balance
 127 between the two electrodes follow the relationship: $Q_+ = Q_-$. The charge storage by
 128 each electrode relates to the C_m , the potential range for discharge process (ΔE) and the
 129 mass of the electrode (m) following the equation [34]:

$$130 \quad Q = C_m \times \Delta E \times m \quad (1)$$

131 In order to get $Q_+ = Q_-$, mass balancing will be calculated as following:

$$132 \quad m_+ / m_- = C_m \times \Delta E_- / C_{m+} \times \Delta E_+ \quad (2)$$

133 On the basis of C_m values and potential windows as for NiS and AC, the optimal
134 mass ratio between the two electrodes should be $m(\text{NiS})/m(\text{AC}) = 0.44$.

135 Cycling voltammetry (CV) and galvanostatic charge-discharge (GCD) were
136 measured on CHI660E electrochemical workstation. Electrochemical impedance
137 spectroscopy (EIS) was conducted on Autolab-PGSTAT in the frequency range
138 between 100 kHz and 0.01 Hz.

139 3. Resulting and discussion

140 3.1. Morphology and structure

141 Fig. 2A shows the XRD patterns of the precursor and NiS. The main
142 characteristic peaks at 12.3° , 24.4° , 34.4° and 59.9° respectively match well with
143 (003), (006), (012) and (110) planes of the $\text{Ni}(\text{OH})_2 \cdot 0.75\text{H}_2\text{O}$ phase (PDF: 38-0715).
144 After vulcanization reaction of precursor, the characteristic peaks of samples transfers
145 to 30.3° , 34.8° , 46.2° , 53.7° and 73.6° , corresponding to the (100), (101), (102), (110)
146 and (202) planes of the NiS phase (PDF: 02-1280), which agree well with the
147 HRTEM. In addition, no impurities peaks are seen in XRD patterns, suggesting high
148 purity of obtained of NiS. And the sharp and narrow characteristic peaks imply the
149 NiS has high crystallinity. EDS spectrum (Fig. S1) further demonstrates that NiS is
150 mainly composed of Ni and S, and the ratio of Ni and S (the inset in Fig. S1) is
151 determined to be about 10:11, which is close to the formula of NiS.

152 From Fig. 2B and Fig. S2A, N_2 adsorption-desorption isotherm of NiS and
153 precursor ($\text{Ni}(\text{OH})_2$), there is a distinct hysteresis loop at a relative pressure of 0.5~1.0,
154 indicating NiS and precursor display type-IV isotherm with a characteristic H3

155 hysteresis loop associated with mesoporous structure and broad pore-size distribution
156 [50]. The Brunauer-Emmett-Teller (BET) surface area of NiS and precursor are 26.3
157 $\text{m}^2\cdot\text{g}^{-1}$ and $175.2 \text{ m}^2\cdot\text{g}^{-1}$, respectively. The BET surface area of NiS appeared
158 decreased compared with the precursor according to the reported literature [9]. The
159 corresponding pore size distribution plot of NiS and precursor are shown in Fig. 2C
160 calculated from adsorption isotherms. It can be clearly seen that the pore size of NiS
161 mainly distributed within the range of 2.07~18.23 nm, while the pore size of precursor
162 (Fig. S2B) was mostly above 2.07 nm from the Barrett-Joyner-Halenda (BJH) method.
163 NiS has a wide pore size distribution and its large dimensional mesoporous is
164 relatively more, corresponding to the obvious hysteresis loop. From Fig. 2C, some
165 large pores are observed due to the stacking nanosheet structure of NiS. The NiS
166 microflower structure provides a large specific surface area and high porosity,
167 facilitate the electrolyte penetration and electrons transfer, and thus improve the
168 capacitive performance [51].

169 To gain information on the chemical states of NiS, XPS measurements were
170 carried out and the results are shown in Fig. 2(D~F). From Fig. 2D, the survey
171 spectrum of NiS, the peaks at 168.7 and 856.2 eV correspond to S 2p and Ni 2p,
172 respectively. In addition, the C and O elements also occur in survey spectrum,
173 attributing to NiS the exposure to air. The Ni 2p and S 2p spectra were fitted by the
174 Gaussian fitting method, shown in Fig. 2E. The Ni 2p spectrum can be fitted with two
175 spin-orbit doublets and two shake-up satellites. The binding energy at 853.2 and 870.5
176 eV correspond to the Ni^{2+} , and the binding energy of 855.9 and 873.8 eV is the

177 characteristic of Ni^{3+} [35,45]. The results showed that Ni existed in two kinds of
178 valence, offering rich redox reactions of NiS. For S 2p spectrum of NiS (Fig. 2F), the
179 binding energy at 161.4 eV suggests that the S element exist as S^{2-} , and the peaks of S
180 $2p_{1/2}$ at 162.5 eV can be owed to sulphur ion in low coordination at NiS surface [52].
181 Meanwhile, the peak at 168.6 eV could be attributed to sulfur oxides at surface [28].

182 Fig. 3A and 3B show SEM images of precursor at different magnifications. As
183 shown in Fig. 3A, the precursor showed the microflower structure, mainly comprised
184 of numerous nanosheets with smooth surface (Fig. 3B). Fig. 3C and 3D depict SEM
185 images of NiS. After sulfidation reaction in absolute ethanol, the NiS samples
186 maintain the microflower structure of the precursor (Fig. 3C) and its surface
187 becomes much rougher compared to that of precursor (Fig. 3D). These coarse
188 surfaces not only provide high specific surface areas, but also improve the
189 wettability of active materials for better electron and electrolyte transmission [48].
190 TEM images (Fig. 3E) clearly reveal that precursor possesses a microflower
191 structure composed of hierarchical nanosheets (Fig. 3F), consistent with SEM results.
192 The hierarchical nanosheet structure can facilitate the access of electrolytes;
193 meanwhile, it is also favorable for structural stability of active materials under
194 repeated GCD process [49]. In agreement with SEM (Fig. 3C and 3D), TEM results
195 further confirm microflower structure of as-obtained NiS (Fig. 3G). Through red
196 areas comparison of Fig. 3F and 3H, the transparency of the precursor is obviously
197 superior NiS, further demonstrating that NiS has rough surface, which is similar to
198 the SEM result in Fig. 3D. A typical HRTEM image of NiS is presented in Fig. 3I.

199 The lattice fringes show the characteristics of NiS, in which the interplanar distance
200 of 0.171, 0.258 and 0.296 nm corresponds to the (110), (101) and (100) plane of NiS.
201 Moreover, orderly lattice fringes reveal the well-crystalline of NiS samples.

202 3.2. Electrochemical performance

203 The electrochemical measurements of as-obtained samples as an electroactive
204 material were performed. Fig. 4A depicts the CV curves of NiS electrode in a
205 potential range from -0.1~0.6 V at various scan rates from 5 $\text{mV}\cdot\text{s}^{-1}$ to 100 $\text{mV}\cdot\text{s}^{-1}$.
206 Obviously, a set of redox peaks is observed, showing typical pseudocapacitive
207 characteristic of NiS. The Faradaic redox of NiS in 3 M KOH electrolyte is shown
208 formula [40]:



210 Notably, CV shapes for NiS has not obvious changes as the scan rate increases,
211 implying its fast charge/discharge capabilities, which is particularly important to
212 power device [46]. In addition, as the scan rate increases, the oxidation and reduction
213 peaks moved to the right and left respectively due to polarization of the NiS [27]. Fig.
214 S3A presents the CV curves of precursor at different scan rates. Apparently, a couple
215 of redox peaks is visible and the redox peaks are almost symmetric with various scan
216 rates, reflecting excellent electrochemical reversibility of precursor electrode.

217 Fig. 4B shows the GCD curves at different current densities within the potential
218 range of 0~0.45 V. Consistent with the redox peak position in the CV curves, the
219 plateaus in GCD curves indicate NiS electrodes exhibit pseudocapacitive behavior.
220 Furthermore, GCD curves at various current densities are highly symmetrical,

221 revealing outstanding electrochemical reversibility. The GCD curves of precursor at
222 different current densities are nearly symmetrical (Fig. S3B), implying the good
223 reversibility of redox reaction.

224 The C_m of NiS and precursor electrodes was calculated by the following
225 equation:

$$226 \quad C_m = I \times \Delta t / (m \times \Delta V) \quad (4)$$

227 Where C_m is the specific capacitance ($F \cdot g^{-1}$), I is the discharge current (A), Δt is
228 the discharge time (s), m is the mass of the active material (g) and ΔV is the potential
229 window during discharge (V). The C_m of NiS and precursor were plotted at different
230 current densities in Fig. 4C. It can be seen that the C_m of NiS evaluated from the
231 discharge curves are 1122.7, 991.6, 913.2, 820.7, 680.3, 465.3 and 323.5 $F \cdot g^{-1}$ at the
232 current densities of 1, 2, 3, 5, 10, 20 and 30 $A \cdot g^{-1}$. Meanwhile, under the same
233 condition of current densities, the C_m of precursor are 686.3, 612.1, 548.3, 465.3,
234 306.7, 154.1 and 96 $F \cdot g^{-1}$, respectively. Even at a high current density of 30 $A \cdot g^{-1}$, NiS
235 and precursor electrodes still remained about 28.9% and 13.9% of the highest C_m .
236 This can be ascribed to the microflower structure with high specific surface area,
237 which is beneficial for the fast transfer of electrons, leading to high specific
238 capacitance and good rate performance. Moreover, the NiS has higher C_m and better
239 rate performance than precursor.

240 The comparison of CV curves for NiS and precursor at a scan rate of 5 $mV \cdot s^{-1}$
241 are shown in Fig. 4D. Apparently, the NiS reveals a larger CV integrated area and
242 higher current density in comparison with that of precursor, suggesting that NiS

243 electrode exhibits much better pseudocapacitive performance and electrochemical
244 reversibility. The excellent electrochemical performance of NiS may be ascribed to
245 the following factors. First, the high surface area of NiS microflowers could improve
246 the surface wetting of the electroactive materials, providing rich electroactive sites.
247 Second, the porous and open structure of NiS microflowers can short diffusion paths
248 for electrons and ions thus enhance the electrochemical kinetics. Finally, the open
249 space of NiS microflowers can act as the robust reservoir for electrolyte ions,
250 supplying sufficient redox reactions for energy storage [38]. GCD curves of NiS and
251 precursor in a potential window of 0~0.45 V at a current density of $1 \text{ A}\cdot\text{g}^{-1}$ are
252 presented in Fig. 4E. It can be observed that the symmetry and charge/discharge time
253 of NiS is superior to the precursor, revealing excellent electrochemical reversibility
254 and capacitive behavior for NiS samples.

255 Nyquist plots of NiS and precursor in the frequency range of $10^{-2}\sim 10^5$ Hz are
256 shown in Fig. 4F. And the equivalent used to fit the impedance curves is also
257 presented (insets in Fig. 4F), which consists of the equivalent series resistance R_s
258 (including the total resistance of ionic resistance of electrolyte, the bulk resistance
259 and the resistance at the interface of the electrolyte/electrode), Warburg impedance W ,
260 charge-transfer R_{ct} , double-layer capacitance C_d and Faradaic pseudocapacitor C_F .
261 Nyquist plots have an inconspicuous arc in the high frequency region and a straight
262 line in the low frequency region. Here, the R_s is calculated based on the semicircle
263 intersect on the real axis. It can be observed that the R_s of NiS and precursor are 0.18
264 and 0.24Ω respectively, which indicate the higher conductivity of NiS compared to

265 precursor. Meanwhile, the diameters of semicircles correspond to the R_{ct} , caused by
266 Faradic reactions. The relatively low value of R_{ct} indicates faster electron transport. As
267 indicated in Fig. 4F, the R_{ct} values, calculated by ZSimpWin software, of NiS (2.99 Ω)
268 is smaller than that of precursor (6.31 Ω), indicating that the charge transfer ability of
269 NiS is superior to precursor [45]. The straight lines in the low frequency region
270 describe the diffusion resistance of ion from the electrolyte solution to the electrode
271 interface. Both the straight lines of NiS and precursor in the Nyquist plots inclined at
272 an angle more than 45°, manifesting that the microflower structure can facilitate
273 electrolyte ions transport and more ideal capacitor behavior [53].

274 The long-term cycling stability is investigated via consecutive GCD tests at a
275 current density of 10 A·g⁻¹ for 1000 cycles (Fig. 4G). The C_m of NiS and precursor
276 maintain about 97.8% and 119.7% of their initial value after 1000 cycles. It can be
277 observed that the C_m of NiS and precursor increase firstly, dropped slightly and finally
278 tend to a stable value. In the initial stage, the C_m of samples slightly increase due to
279 the activation of the active material, and then gradually decreased and finally tend to
280 stable attributed to the degradation of active material to some extent at KOH
281 electrolyte during subsequent GCD processes [34]. After 1000 cycles, the NiS
282 electrode exhibits a relatively high C_m , demonstrating the microflower structure can
283 act as buffer for the volume change in GCD process as well as convenient ion
284 diffusion channels [54]. In addition, the GCD curves of the last 20 cycles of NiS
285 electrode are shown as the Fig. 4H. Obviously, the GCD curves reveal a good
286 symmetry and reproducibility, further confirming the superior redox reversibility.

287 The CV curves of NiS before and after 1000 GCD cycles at scan rate of $5 \text{ mV}\cdot\text{s}^{-1}$
288 are displayed in Fig. 5A. As shown in Fig. 5A, the CV curves are almost coincident,
289 indicating the high stability of the NiS electrode. Fig. 5B, the Nyquist plots before and
290 after 1000 GCD cycles, show obviously that the R_s values were increased from 0.22Ω
291 to 0.24Ω , meanwhile, the value of R_{ct} increased from 2.99Ω to 4.24Ω . Moreover, the
292 slight decrease of the slope for the straight line after 1000 GCD cycles. These results
293 further confirm the highly cycling stability and good reversible redox reaction of the
294 NiS. Fig. 5C and 5D show the SEM images of NiS before and after 1000 GCD tests.
295 In comparison Fig. 5C with 5D, the NiS nanosheets become bent after cycling test.
296 Such good stability of NiS is possibly attributed to the nanosheet structure, which can
297 act as buffer for the volume shrinking and expanding during consecutive GCD
298 process. Fig. S4 shows the XRD patterns of NiS electrodes before and after 1000
299 GCD cycles. It shows that the crystallinity degree slight decreased after GCD cycles.
300 This phenomenon maybe from the fact that the consecutive GCD process makes
301 volume of NiS electrode shrinkage and expansion constantly, leading to the
302 crystallinity degree reduced. The evolution in crystallinity corresponds to the results
303 of Fig. 5C and 5D.

304 As illustrated in Fig. 6A, the potential window of NiS electrode is within
305 $-0.1\sim 0.6 \text{ V}$, while AC electrode within $-0.1\sim 0 \text{ V}$ at scan rate of $5 \text{ mV}\cdot\text{s}^{-1}$. Moreover,
306 the potential window of Ni//AC could be extended to 1.8 V , which is favorable for
307 improving its energy density (Fig. 6B and 6C). Fig. 6B shows the CV curves of
308 Ni//AC at different scan rate. The redox peak could be explicitly observed, attributing

309 to NiS pseudocapacitance. With the scan rate increasing from $5 \text{ mV}\cdot\text{s}^{-1}$ to $100 \text{ mV}\cdot\text{s}^{-1}$,
 310 the shape of CV curves has not obvious distortion, indicating fast charge/discharge
 311 property for Ni//AC [34]. Furthermore, from Fig. 6C, the GCD curves of Ni//AC are
 312 different from that of linear characteristic of EDLCs, indicating coexistence
 313 accumulation of electrostatic and redox reaction at electrode/electrolyte interfaces.
 314 Meanwhile, the GCD curves at different current densities are almost symmetric,
 315 demonstrating the excellent capacitance behavior. The C_m based on discharge curves
 316 at different current densities is calculated, displayed in Fig. 6D. The NiS//AC shows a
 317 C_m of 69.1, 57.7, 51.6, 44.9 and $30.2 \text{ F}\cdot\text{g}^{-1}$ at different current densities of 1, 2, 3, 5
 318 and $10 \text{ A}\cdot\text{g}^{-1}$. The C_m at $10 \text{ A}\cdot\text{g}^{-1}$ still remained about 48.8% of that at $1 \text{ A}\cdot\text{g}^{-1}$,
 319 suggesting NiS//AC good rate capability.

320 Ragone plot for NiS//AC is shown in Fig. 6E. The energy density and power
 321 density were calculated according to the following equation:

$$322 \quad E = C_m \times (\Delta V)^2 / 7.2 \quad (5)$$

$$323 \quad P = 3.6 \times E / \Delta t \quad (6)$$

324 Where E is the energy density ($\text{Wh}\cdot\text{kg}^{-1}$), C_m is the specific capacitance ($\text{F}\cdot\text{g}^{-1}$),
 325 ΔV is the potential window for the discharge (V), P is the power density ($\text{kW}\cdot\text{kg}^{-1}$)
 326 and Δt is the discharge time (s). The NiS//AC can deliver an energy density of 31
 327 $\text{Wh}\cdot\text{kg}^{-1}$ at a power density of $0.9 \text{ kW}\cdot\text{kg}^{-1}$ and still remain $12.9 \text{ Wh}\cdot\text{kg}^{-1}$ at power
 328 density of $8.8 \text{ kW}\cdot\text{kg}^{-1}$. As is generally known, the wide potential window of NiS//AC
 329 is a critical factor to improve the energy density.

330 The cycle life of the NiS//AC was evaluated by repeating GCD test for 1000

331 cycles at a current density of $5 \text{ A}\cdot\text{g}^{-1}$, as depicted in Fig. 6F. With the increase of cycle
332 number, the C_m of NiS//AC increased first, and then tend to be stable. After 1000
333 cycles, the NiS//AC still retains 114.1% of its initial C_m . This indicates long-term
334 cycle life of NiS//AC. Furthermore, the NiS//AC maintains a highly electrochemical
335 reversibility with nearly 100% Coulombic efficiency after 1000 GCD cycles. The
336 above-mentioned results reveal that the NiS//AC has superior capacitive performance
337 due to NiS with large specific surface area, which are expected to improve the
338 wettability of electroactive materials for enhancing the density of active sites.

339 4. Conclusions

340 In conclusion, the hierarchical NiS microflowers with superior capacitive
341 performance were obtained through a facile two-step method. The NiS not only
342 provide large specific surface area ($26.3 \text{ m}^2\cdot\text{g}^{-1}$), but also have a rough surface, which
343 improve the active material/electrolyte contact area, shorten the diffusion pathway for
344 ions. Electrochemical measurements results show that as-prepared NiS exhibited a
345 high C_m ($1122.7 \text{ F}\cdot\text{g}^{-1}$ at $1 \text{ A}\cdot\text{g}^{-1}$), low R_s ($0.18 \text{ }\Omega$) and R_{ct} ($2.99 \text{ }\Omega$), optimal rate
346 capability and long cycle life (97.8% retention of C_m at $10 \text{ A}\cdot\text{g}^{-1}$ after 1000 cycles).
347 Additionally, the NiS//AC, NiS as the positive electrode and AC as the negative
348 electrode, has an operating voltage up to 1.8 V in 3 M KOH electrolyte, and delivers
349 an energy density of $31 \text{ Wh}\cdot\text{kg}^{-1}$ at a power density of $0.9 \text{ kW}\cdot\text{kg}^{-1}$. In addition, the
350 NiS//AC exhibits good electrochemical stability: the C_m retention is 114.1% at $5 \text{ A}\cdot\text{g}^{-1}$
351 and Coulombic efficiency after 1000 cycles retains nearly 100%. All above results
352 signifies that NiS microflowers possess excellent capacitive performance, making it

353 highly promising electrode materials for SCs.

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529 **Fig. 1.** Synthesis of hierarchical NiS microflowers.

530 **Fig. 2.** (A) XRD patterns of precursor and NiS; (B) N₂ adsorption-desorption isotherm and (C)
531 pore size distribution curve for NiS; (D) XPS survey spectra of NiS; (E) Ni 2p and (F) S
532 2p.

533 **Fig. 3.** SEM images of precursor (A, B) and NiS (C, D); TEM images of precursor (E, F) and NiS
534 (G, H); (I) HRTEM image of NiS.

535 **Fig. 4.** Electrochemical performance of NiS: (A) CV curves at different scan rates, (B) GCD
536 curves at different current densities; Electrochemical performance of NiS and precursor
537 (Ni(OH)₂): (C) C_m at different current densities, (D) CV curves at scan rate of 5 mV·s⁻¹, (E)
538 the GCD curves at current density of 1 A·g⁻¹, (F) Nyquist plots, inset shows the
539 corresponding equivalent circuit, (G) Cycling life at 10 A·g⁻¹; (H) The last 20 GCD cycles
540 of NiS.

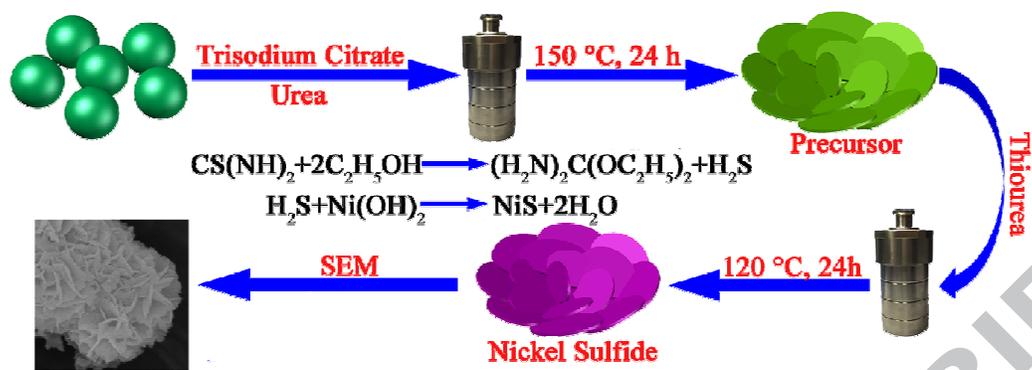
541 **Fig. 5.** (A) CV curves, (B) Nyquist plots and (C, D) SEM images of NiS electrode before and after
542 1000 cycles.

543 **Fig. 6.** (A) CV curves of NiS and AC electrodes at scan rate of 5 mV·s⁻¹; electrochemical
544 performance of Ni//AC: (B) CV curves at different scan rates, (C) GCD curves at different
545 current densities, (D) Variation of C_m at different current densities, (E) Ragone plot and (F)
546 Cycle life and Coulombic efficiency at current density of 5 A·g⁻¹.

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Fig. 1.

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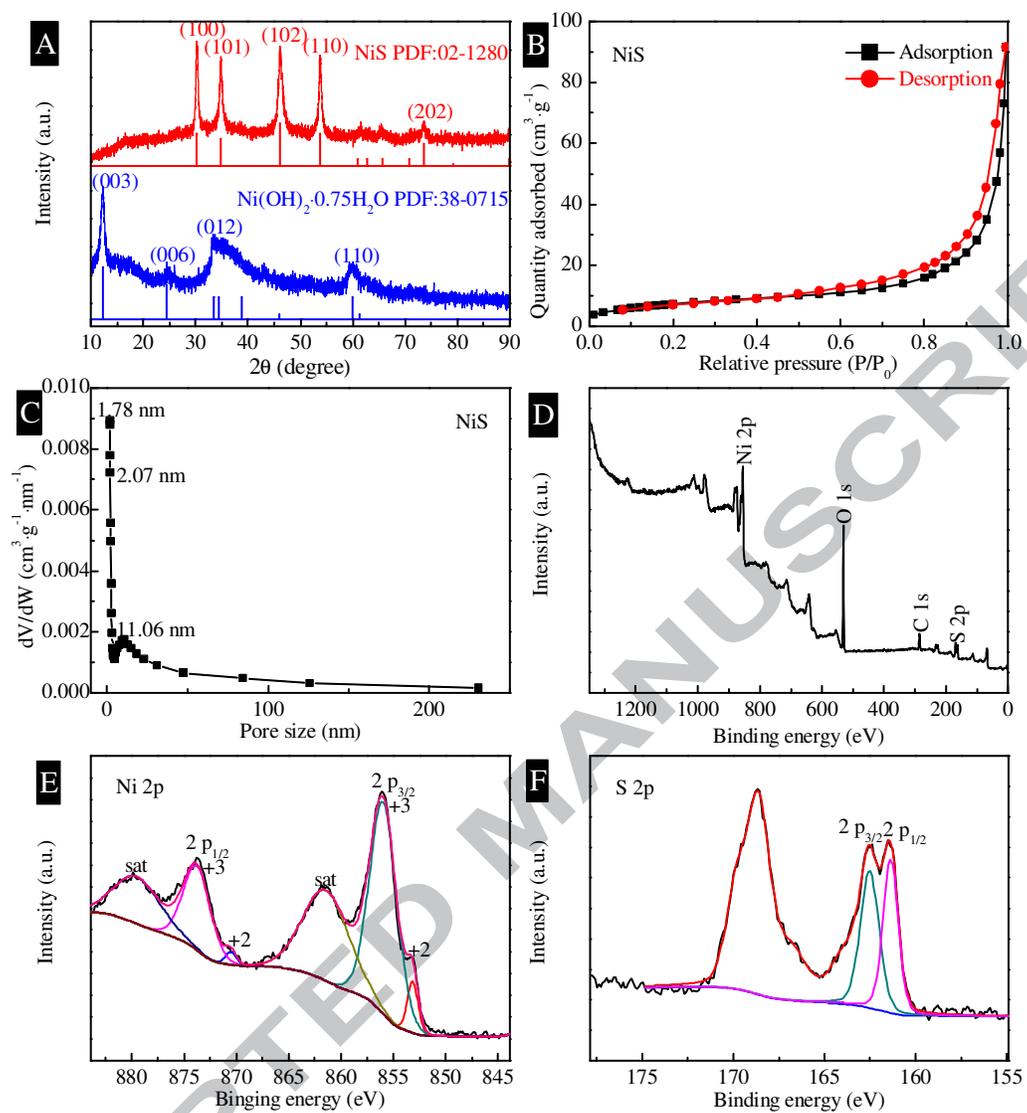


Fig. 2.

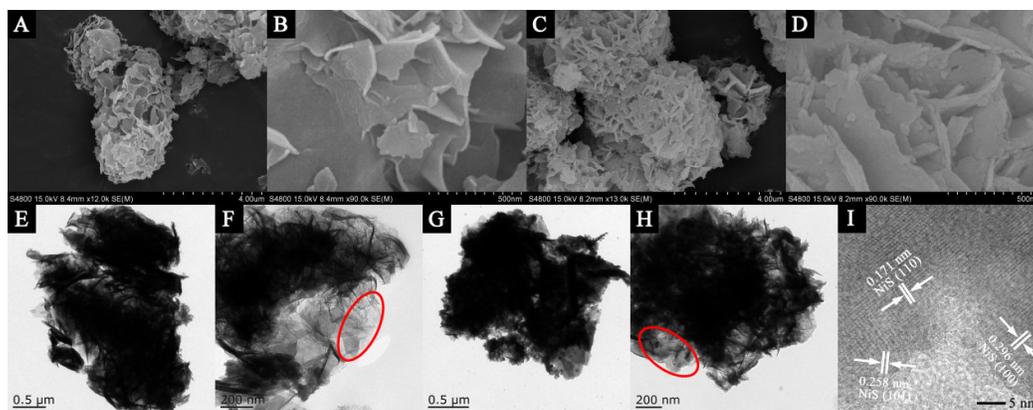
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Fig. 3.

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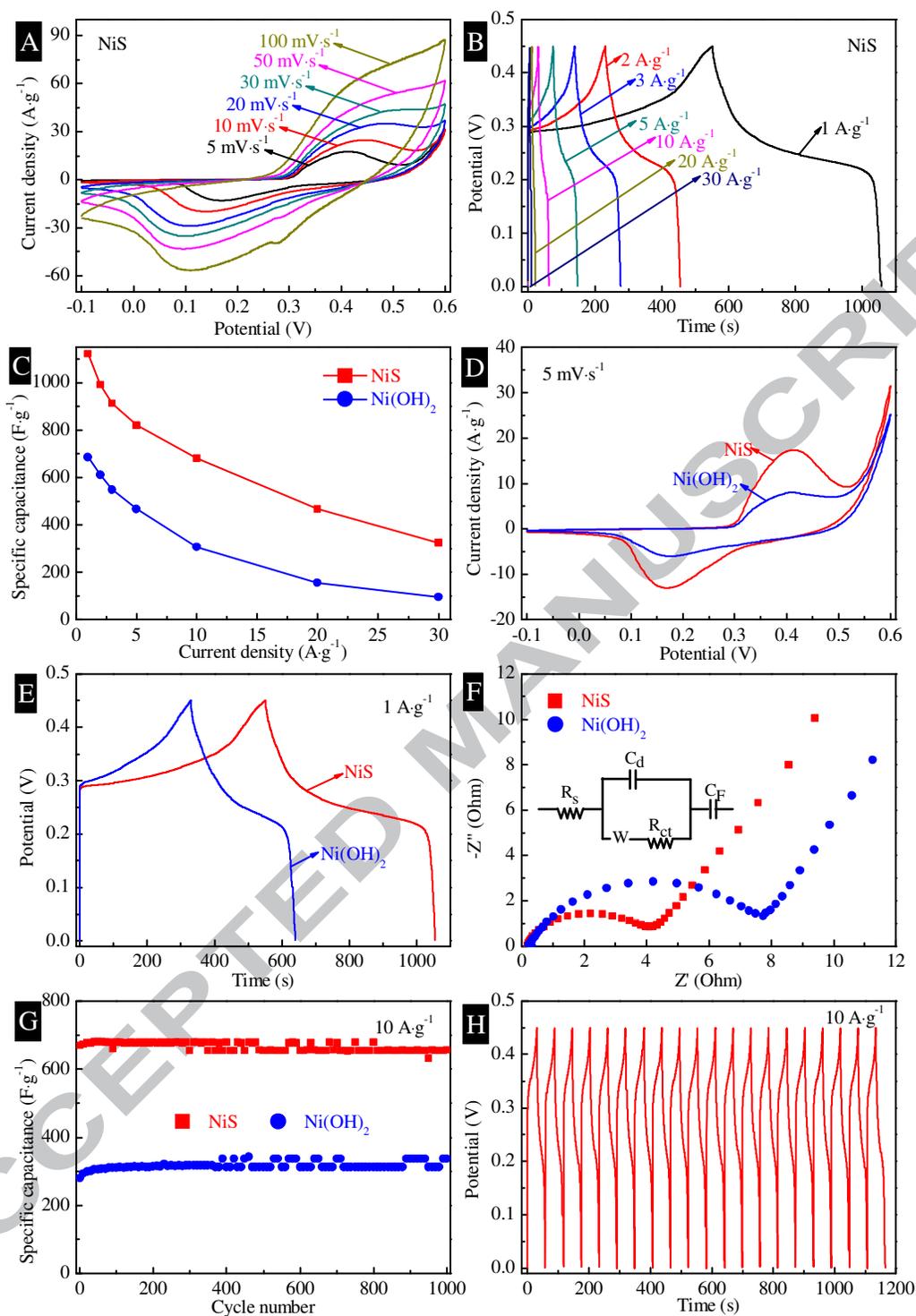


Fig. 4.

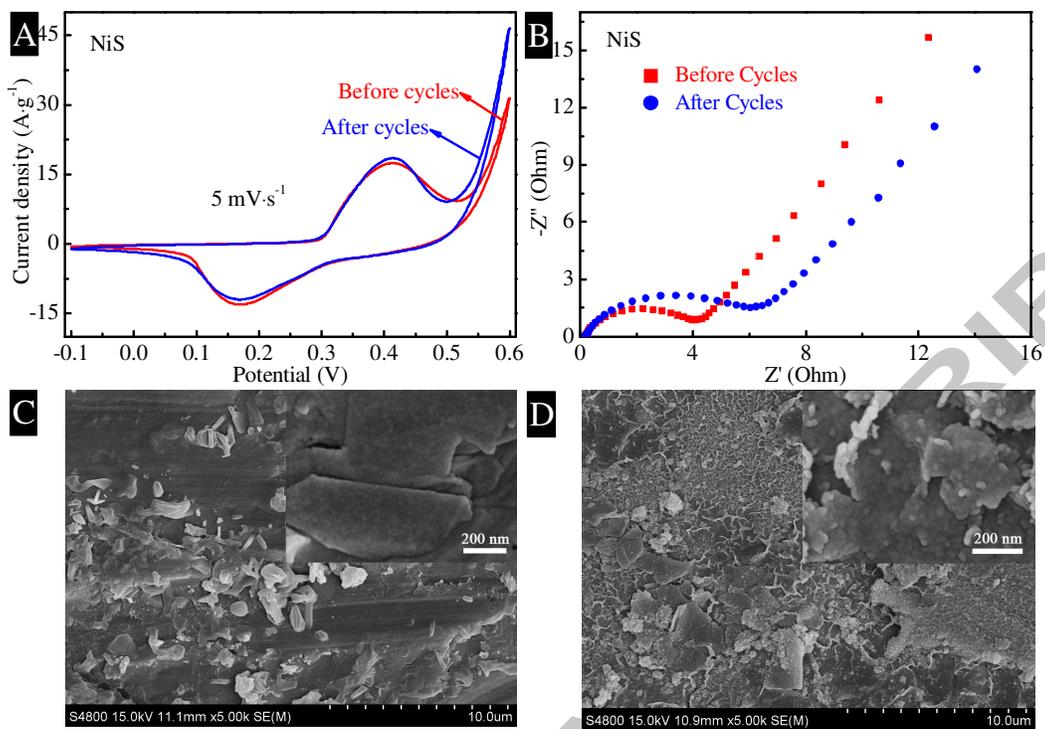
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Fig. 5.

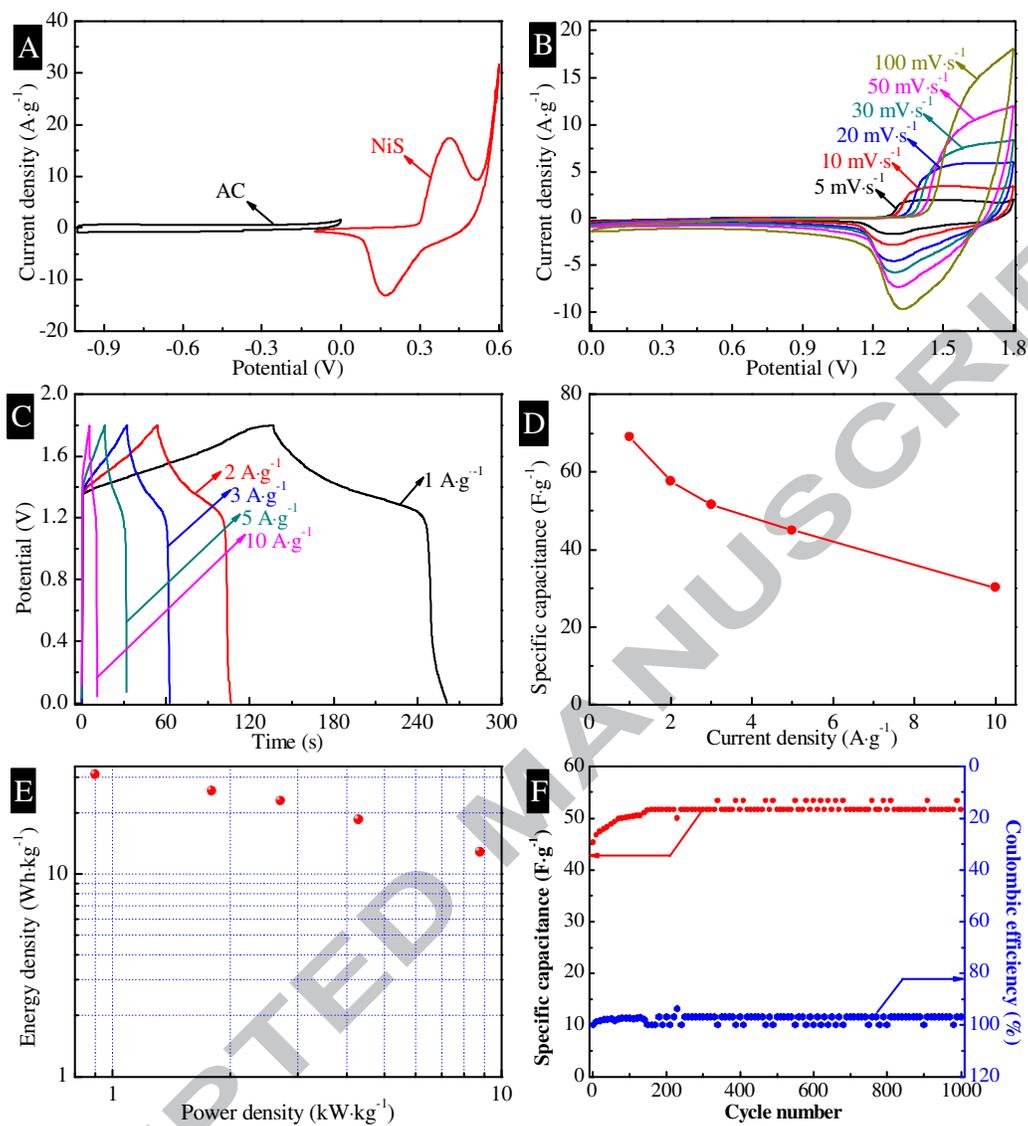


Fig. 6.

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583 **Table 1** Comparison of the C_m of NiS electrodes with different forms from recent reports.

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Table 1

Sample	Current density	Electrolyte	C_m (F·g ⁻¹)	Ref.
NiS microflower	1 A·g ⁻¹	3 M KOH	1122.7	This work
graphene nanosheets/NiS film	0.5 A·g ⁻¹	6 M KOH	775	40
NiS hollow spheres	4.08 A·g ⁻¹	2 M KOH	927	43
NiS nanoparticles	1 A·g ⁻¹	6 M KOH	845	45
NiS nanosheets	2.5 mA·cm ⁻²	2 M KOH	527	46

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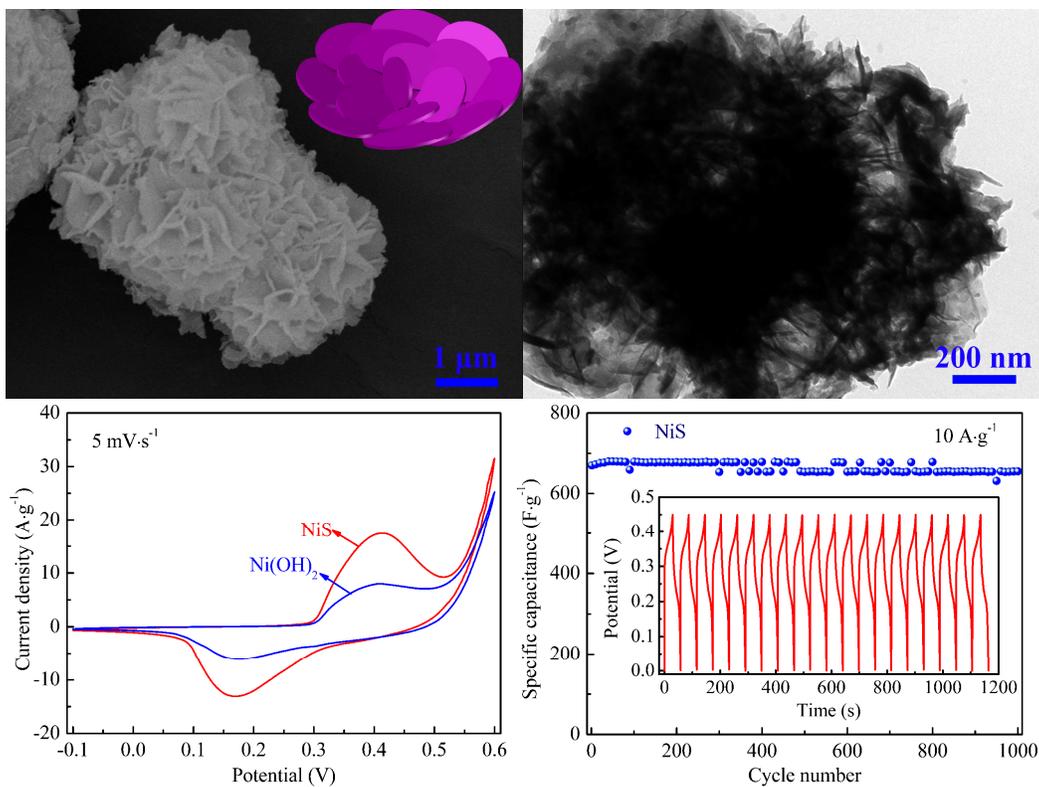
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595 Hierarchical NiS microflowers were synthesized by a facile two-step method.

596 Electrochemical measurements results show that the NiS owns the much high C_m and

597 long cycle life.

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601 **Highlights**

602 1. New hierarchical NiS microflowers with high capacitance performance were
603 prepared.

604 2. Specific capacitance of NiS is up to $1122.7 \text{ F}\cdot\text{g}^{-1}$ at current density of $1 \text{ A}\cdot\text{g}^{-1}$.

605 3. Capacitance retention of NiS electrode after 1000 galvanostatic charge-discharge
606 cycles is 97.8%.

607 4. NiS//AC delivers an energy density of $31 \text{ Wh}\cdot\text{kg}^{-1}$ at a power density of 0.9
608 $\text{kW}\cdot\text{kg}^{-1}$.

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